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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Confirmation No. 4981

Hiroshi TAKANASHI et al.

Docket No. 2000-1749

Serial No. 09/739,750

Group Art Unit 1752

Filed December 20, 2000

Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE  
RESIN COMPOSITION AND PHOTOSENSITIVE  
RESIN PLATE USING THE SAME

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents

P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a five month extension of time to file an Appeal Brief in connection with the Notice of Appeal filed on December 19, 2003.

The fee of \$1,970.00 is

submitted herewith.  
 to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.  
  
 Small entity status of this application is established by a Small Entity Status Assertion which  
 is enclosed.  
 has been previously submitted.

07/22/2003 KZEWIDIE 00000031 09739750

Respectfully submitted,

01 FC:1255

1970.00 OP

Hiroshi TAKANASHI et al.

By   
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July 21, 2003